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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/602,054	06/24/2003	Dae-Ho Choo	61920219D1	1023
22150 7550 99003/2008 F. CHAU & ASSOCIATES, LLC 130 WOODBURY ROAD			EXAMINER	
			RUDE, TIMOTHY L	
WOODBURY, NY 11797			ART UNIT	PAPER NUMBER
			2871	
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			09/03/2008	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

# Application No. Applicant(s) 10/602.054 CHOO ET AL. Office Action Summary Examiner Art Unit TIMOTHY RUDE 2871 -- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --Period for Reply A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS. WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status 1) Responsive to communication(s) filed on 22 April 2008. 2a) ☐ This action is FINAL. 2b) This action is non-final. 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. Disposition of Claims 4) Claim(s) 57-77 is/are pending in the application. 4a) Of the above claim(s) 59 and 66-77 is/are withdrawn from consideration. 5) Claim(s) \_\_\_\_\_ is/are allowed. 6) Claim(s) 57.58 and 60-65 is/are rejected. 7) Claim(s) \_\_\_\_\_ is/are objected to. 8) Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement. Application Papers 9) The specification is objected to by the Examiner. 10) The drawing(s) filed on is/are; a) accepted or b) objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abevance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. Priority under 35 U.S.C. § 119 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some \* c) None of: Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). \* See the attached detailed Office action for a list of the certified copies not received.

PTOL-326 (Rev. 08-06)

1) Notice of References Cited (PTO-892)

Notice of Draftsperson's Patent Drawing Review (PTO-948)

Information Disclosure Statement(s) (PTO/S5/08)
 Paper No(s)/Mail Date \_\_\_\_\_\_.

Attachment(s)

Interview Summary (PTO-413)
 Paper No(s)/Mail Date.

6) Other:

Notice of Informal Patent Application

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### DETAILED ACTION

### Claims

Claim 77 is added

#### Election/Restrictions

Applicant's election without traverse of species B and D in the replies filed on 03 April 2008, 22 April 2008, and as completed by telephone with Scott L. Applebaum on 20 May 2008 is acknowledged. Applicant argues claims 57-65 and 77 read on the elected species.

Claims 59, 66-68, and 77 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected species, there being no allowable generic or linking claim. Election was made **without** traverse in the reply filed on 20 May 2008. Please note, claim 59 (and consequently dependent claim77) reads on nonelected species A.

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made. Application/Control Number: 10/602,054 Page 3

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The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

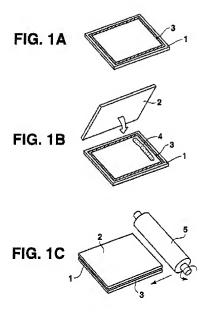
- Determining the scope and contents of the prior art.
- 2. Ascertaining the differences between the prior art and the claims at issue.
- Resolving the level of ordinary skill in the pertinent art.
- Considering objective evidence present in the application indicating obviousness or nonobviousness.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

 Claim 57 is rejected under 35 U.S.C. 103(a) as being unpatentable over Kawasumi et al (Kawasumi) USPAT 5,978,065 in view of Adachi, Japanese patent application publication JP 56114928 A. Application/Control Number: 10/602,054 Page 4

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As to claim 57, Kawasumi discloses (Figures 1A-3B) apparatus and a method [system or apparatus] for manufacturing liquid crystal displays (entire patent, background of the invention, and especially col. 5, line 13 through col. 7, line 14), comprising: applying sealant on one of two substrates of a mother glass, the mother glass having at least one liquid crystal cell (col. 5, lines 14-37) [inherently requires Applicant's sealant applying unit, even if it is manual], a substrate-attaching unit, 5 and 7, conjoining substrates in a vacuum (background, suitable though more costly method – affords better degasification of liquid crystal material). Please note numerous references teach these steps/apparatus.



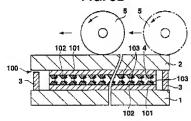
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FIG. 2

FIG. 3A



FIG. 3B

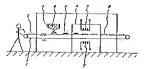


Kawasumi does not explicitly disclose the use of first loading unit and an in-line conveying unit.

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Adachi teaches the use of a first loading unit [at left in illustration] and a belt conveyor to provide a cleaner environment for the operators.



Adachi is evidence that ordinary workers in the art of liquid crystals would find the reason, suggestion, or motivation to add the use of a first loading unit and a belt conveyor to provide a cleaner environment for the operators.

Therefore, it would have been obvious to one having ordinary skill in the art of liquid crystals at the time the invention was made to modify the LCD system of Kawasumi with the first loading unit and a belt conveyor of Adachi to provide a cleaner environment for the operators.

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 Claims 58 and 60 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kawasumi in view of Adachi as applied to claim 57 above, and further in view of Deem USPAT 2,394,293.

Kawasumi in view of Abachi teach the in-line system of claim 57.

Kawasumi in view of Abachi do not explicitly teach an apparatus wherein the substrate-attaching unit includes two or more vacuum chambers arranged in parallel.

Deem teaches that multiple vacuum [exhausting] sections, in an in-line manufacturing apparatus, may "obviously be placed in parallel to secure any desired through put or capacity over and beyond that obtainable with one unit." [page 3, right column, lines 5-14].

Deem is evidence that ordinary workers in the art of liquid crystals would find the reason, suggestion, or motivation to add the use of multiple vacuum chambers, in an inline manufacturing apparatus, placed in parallel to secure any desired through put or capacity over and beyond that obtainable with one unit." [page 3, right column, lines 5-14].

Therefore, it would have been obvious to one having ordinary skill in the art of liquid crystals at the time the invention was made to modify the LCD system of Kawasumi and Adachi with the multiple vacuum chambers of Deem, in an in-line manufacturing apparatus, placed in parallel to secure any desired through put or capacity over and beyond that obtainable with one unit." [page 3, right column, lines 5-14].

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 Claims 61-65 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kawasumi in view of Adachi and further in view of Harada et al (Harada) USPAT 5,731,860.

As to claims 61-65, Kawasumi in view of Abachi teach the in-line system of claim 57.

Kawasumi in view of Abachi do not explicitly teach the use of vacuum chucks with holes and a vacuum sequence in the substrate attaching and sealant curing processes.

Harada teaches the use of such an apparatus to achieve precision cell gap and high production yield [Abstract and entire disclosure].

Harada is evidence that ordinary workers in the art of liquid crystals would find the reason, suggestion, or motivation to add the use of vacuum chucks with holes and a vacuum sequence [col. 8, lines 31-56] in the substrate attaching and sealant curing processes to achieve precision cell gap and high production yield [Abstract and entire disclosure].

Therefore, it would have been obvious to one having ordinary skill in the art of liquid crystals at the time the invention was made to modify the LCD system of Kawasumi and Adachi with the vacuum chucks with holes and a vacuum sequence [col. 8, lines 31-56] of Harada in the substrate attaching and sealant curing processes to achieve precision cell gap and high production yield [Abstract and entire disclosure].

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Please note the principles of vacuum chucking and vacuum sequence [col. 8, lines 31-56] are robustly taught by Harada in such a way as to render numerous minor structural variations (e.g., tubes, slits, holes, etc.) obvious to one of ordinary skill in the art.

## Conclusion

Any references cited but not applied are relevant to the instant Application.

Korean publication 100487258 B1 provided in IDS filed 18 September 2006 is considered relevant to the instant Application.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to TIMOTHY RUDE whose telephone number is (571)272-2301. The examiner can normally be reached on Increased Flex Time Program.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nelms C. David can be reached on (571) 272-1787. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

tlr

/TIMOTHY RUDE/

Primary Examiner, Art Unit 2871